

## 2A, 100V, 0.170 Ohm, Rad Hard, SEGR Resistant, N-Channel Power MOSFETs

The Discrete Products Operation of Intersil Corporation has developed a series of Radiation Hardened MOSFETs specifically designed for commercial and military space applications. Enhanced Power MOSFET immunity to Single Event Effects (SEE), Single Event Gate Rupture (SEGR) in particular, is combined with 100K RADS of total dose hardness to provide devices which are ideally suited to harsh space environments. The dose rate and neutron tolerance necessary for military applications have not been sacrificed.

The Intersil portfolio of SEGR resistant radiation hardened MOSFETs includes N-Channel and P-Channel devices in a variety of voltage, current and on-resistance ratings. Numerous packaging options are also available.

This MOSFET is an enhancement-mode silicon-gate power field-effect transistor of the vertical DMOS (VDMOS) structure. It is specially designed and processed to be radiation tolerant. The MOSFET is well suited for applications exposed to radiation environments such as switching regulation, switching converters, motor drives, relay drivers and drivers for high-power bipolar switching transistors requiring high speed and low gate drive power. This type can be operated directly from integrated circuits.

Reliability screening is available as either commercial, TXV equivalent of MIL-S-19500, or Space equivalent of MIL-S-19500. Contact Intersil for any desired deviations from the data sheet.

Formerly available as type TA17696.

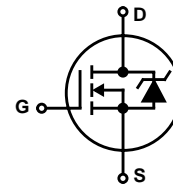
### Ordering Information

RAD LEVEL	SCREENING LEVEL	PART NUMBER/BRAND
10K	Commercial	FSS13A0D1
10K	TXV	FSS13A0D3
100K	Commercial	FSS13A0R1
100K	TXV	FSS13A0R3
100K	Space	FSS13A0R4

### Features

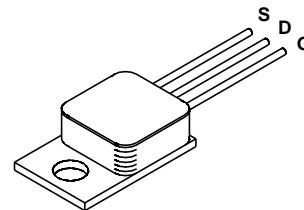
- 12A, 100V,  $r_{DS(ON)} = 0.170\Omega$
- Total Dose
  - Meets Pre-RAD Specifications to 100K RAD (Si)
- Single Event
  - Safe Operating Area Curve for Single Event Effects
  - SEE Immunity for LET of 36MeV/mg/cm<sup>2</sup> with  $V_{DS}$  up to 80% of Rated Breakdown and  $V_{GS}$  of 10V Off-Bias
- Dose Rate
  - Typically Survives 3E9 RAD (Si)/s at 80%  $BV_{DSS}$
  - Typically Survives 2E12 if Current Limited to  $I_{DM}$
- Photo Current
  - 1.5nA Per-RAD(Si)/s Typically
- Neutron
  - Maintain Pre-RAD Specifications for 3E13 Neutrons/cm<sup>2</sup>
  - Usable to 3E14 Neutrons/cm<sup>2</sup>

### Symbol



### Packaging

TO-257AA



CAUTION: Beryllia Warning per MIL-S-19500 refer to package specifications.

# FSS13A0D, FSS13A0R

## Absolute Maximum Ratings $T_C = 25^\circ\text{C}$ , Unless Otherwise Specified

	FSS13A0D, FSS13A0R	UNITS
Drain to Source Voltage	$V_{DS}$ 100	V
Drain to Gate Voltage ( $R_{GS} = 20k\Omega$ )	$V_{DGR}$ 100	V
Continuous Drain Current		
$T_C = 25^\circ\text{C}$	$I_D$ 12	A
$T_C = 100^\circ\text{C}$	$I_D$ 9	A
Pulsed Drain Current	$I_{DM}$ 36	A
Gate to Source Voltage	$V_{GS}$ $\pm 20$	V
Maximum Power Dissipation		
$T_C = 25^\circ\text{C}$	$P_T$ 56	W
$T_C = 100^\circ\text{C}$	$P_T$ 22	W
Linear Derating Factor	0.45	W/ $^\circ\text{C}$
Single Pulsed Avalanche Current, $L = 100\mu\text{H}$ , (See Test Figure)	$I_{AS}$ 36	A
Continuous Source Current (Body Diode)	$I_S$ 12	A
Pulsed Source Current (Body Diode)	$I_{SM}$ 36	A
Operating and Storage Temperature	$T_J, T_{STG}$ -55 to 150	$^\circ\text{C}$
Lead Temperature (During Soldering) (Distance $>0.063\text{in}$ (1.6mm) from Case, 10s Max)	$T_L$ 300	$^\circ\text{C}$

CAUTION: Stresses above those listed in "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress only rating and operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied.

## Electrical Specifications $T_C = 25^\circ\text{C}$ , Unless Otherwise Specified

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	TYP	MAX	UNITS	
Drain to Source Breakdown Voltage	$BV_{DSS}$	$I_D = 1\text{mA}, V_{GS} = 0\text{V}$	100	-	-	V	
Gate Threshold Voltage	$V_{GS(TH)}$	$V_{GS} = V_{DS}, I_D = 1\text{mA}$	$T_C = -55^\circ\text{C}$	-	-	5.0	V
			$T_C = 25^\circ\text{C}$	1.5	-	4.0	V
			$T_C = 125^\circ\text{C}$	0.5	-	-	V
Zero Gate Voltage Drain Current	$I_{DSS}$	$V_{DS} = 80\text{V}, V_{GS} = 0\text{V}$	$T_C = 25^\circ\text{C}$	-	-	25	$\mu\text{A}$
			$T_C = 125^\circ\text{C}$	-	-	250	$\mu\text{A}$
Gate to Source Leakage Current	$I_{GSS}$	$V_{GS} = \pm 20\text{V}$	$T_C = 25^\circ\text{C}$	-	-	100	nA
			$T_C = 125^\circ\text{C}$	-	-	200	nA
Drain to Source On-State Voltage	$V_{DS(ON)}$	$V_{GS} = 12\text{V}, I_D = 12\text{A}$	-	-	2.32	V	
Drain to Source On Resistance	$r_{DS(ON)12}$	$I_D = 9\text{A}, V_{GS} = 12\text{V}$	$T_C = 25^\circ\text{C}$	-	0.100	0.170	$\Omega$
			$T_C = 125^\circ\text{C}$	-	-	0.289	$\Omega$
Turn-On Delay Time	$t_{d(ON)}$	$V_{DD} = 50\text{V}, I_D = 12\text{A}, R_L = 4.17\Omega, V_{GS} = 12\text{V}, R_{GS} = 7.5\Omega$	-	-	20	ns	
Rise Time	$t_r$		-	-	75	ns	
Turn-Off Delay Time	$t_{d(OFF)}$		-	-	45	ns	
Fall Time	$t_f$		-	-	25	ns	
Total Gate Charge	$Q_g(TOT)$		$V_{GS} = 0\text{V to } 20\text{V}$	-	-	61	nC
Gate Charge at 12V	$Q_g(12)$	$V_{GS} = 0\text{V to } 12\text{V}$	-	35	42	nC	
Threshold Gate Charge	$Q_g(TH)$	$V_{GS} = 0\text{V to } 2\text{V}$	-	-	-	nC	
Gate Charge Source	$Q_{gs}$		-	6.8	8.3	nC	
Gate Charge Drain	$Q_{gd}$		-	20	22	nC	
Plateau Voltage	$V_{(PLATEAU)}$	$I_D = 12\text{A}, V_{DS} = 15\text{V}$	-	8	-	V	
Input Capacitance	$C_{ISS}$	$V_{DS} = 25\text{V}, V_{GS} = 0\text{V}, f = 1\text{MHz}$	-	760	-	pF	
Output Capacitance	$C_{OSS}$		-	310	-	pF	
Reverse Transfer Capacitance	$C_{RSS}$		-	110	-	pF	
Thermal Resistance Junction to Case	$R_{\theta JC}$		-	-	2.2	$^\circ\text{C/W}$	
Thermal Resistance Junction to Ambient	$R_{\theta JA}$		-	-	60	$^\circ\text{C/W}$	

Source to Drain Diode Specifications

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	TYP	MAX	UNITS
Forward Voltage	$V_{SD}$	$I_{SD} = 12A$	0.6	-	1.8	V
Reverse Recovery Time	$t_{rr}$	$I_{SD} = 12A, dI_{SD}/dt = 100A/\mu s$	-	-	280	ns

Electrical Specifications up to 100K RAD  $T_C = 25^\circ C$ , Unless Otherwise Specified

PARAMETER	SYMBOL	TEST CONDITIONS	MIN	MAX	UNITS
Drain to Source Breakdown Volts	(Note 3)	$BV_{DSS}$ $V_{GS} = 0, I_D = 1mA$	100	-	V
Gate to Source Threshold Volts	(Note 3)	$V_{GS(TH)}$ $V_{GS} = V_{DS}, I_D = 1mA$	1.5	4.0	V
Gate to Body Leakage	(Notes 2, 3)	$I_{GSS}$ $V_{GS} = \pm 20V, V_{DS} = 0V$	-	100	nA
Zero Gate Leakage	(Note 3)	$I_{DSS}$ $V_{GS} = 0, V_{DS} = 80V$	-	25	$\mu A$
Drain to Source On-State Volts	(Notes 1, 3)	$V_{DS(ON)}$ $V_{GS} = 12V, I_D = 12A$	-	2.32	V
Drain to Source On Resistance	(Notes 1, 3)	$r_{DS(ON)12}$ $V_{GS} = 12V, I_D = 9A$	-	0.170	$\Omega$

NOTES:

1. Pulse test, 300 $\mu s$  Max.
2. Absolute value.
3. Insitu Gamma bias must be sampled for both  $V_{GS} = 12V, V_{DS} = 0V$  and  $V_{GS} = 0V, V_{DS} = 80\% BV_{DSS}$ .

Single Event Effects (SEB, SEGR) Note 4

TEST	SYMBOL	ENVIRONMENT (NOTE 5)			APPLIED $V_{GS}$ BIAS (V)	(NOTE 6) MAXIMUM $V_{DS}$ BIAS (V)
		ION SPECIES	TYPICAL LET (MeV/mg/cm)	TYPICAL RANGE ( $\mu$ )		
Single Event Effects Safe Operating Area	SEESOAS	Ni	26	43	-20	100
		Br	37	36	-10	100
		Br	37	36	-15	80
		Br	37	36	-20	50

NOTES:

4. Testing conducted at Brookhaven National Labs; sponsored by Naval Surface Warfare Center (NSWC), Crane, IN.
5. Fluence = 1E5 ions/cm<sup>2</sup> (typical), T = 25 $^\circ C$ .
6. Does not exhibit Single Event Burnout (SEB) or Single Event Gate Rupture (SEGR).

Typical Performance Curves Unless Otherwise Specified

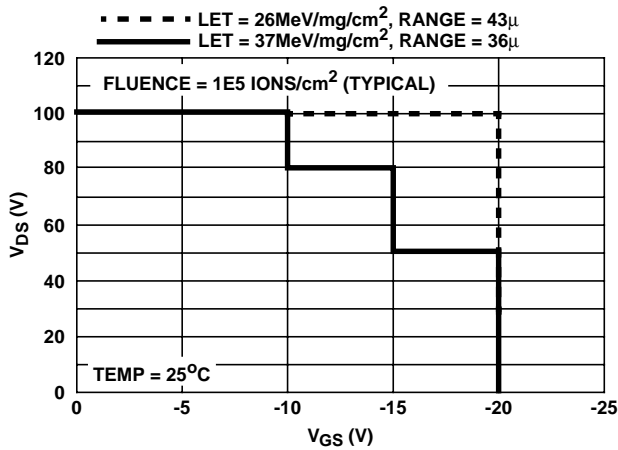


FIGURE 1. SINGLE EVENT EFFECTS SAFE OPERATING AREA

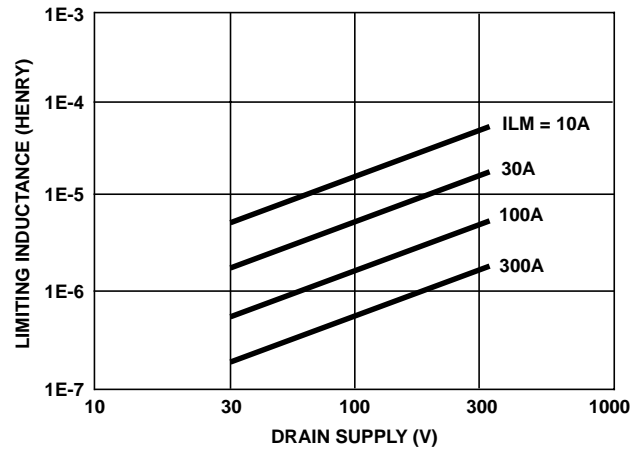


FIGURE 2. DRAIN INDUCTANCE REQUIRED TO LIMIT GAMMA DOT CURRENT TO  $I_{AS}$

Typical Performance Curves Unless Otherwise Specified (Continued)

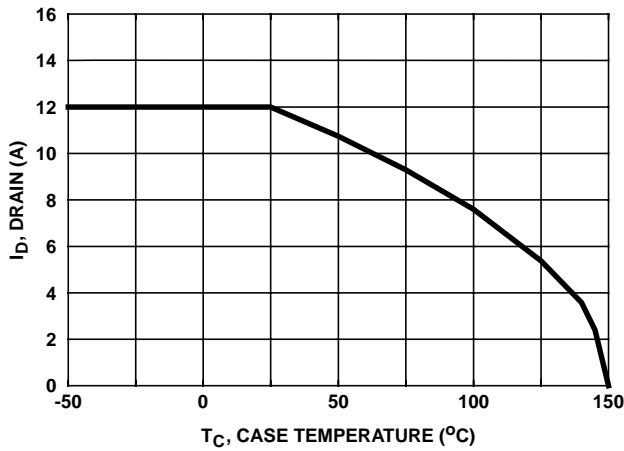


FIGURE 3. MAXIMUM CONTINUOUS DRAIN CURRENT vs TEMPERATURE

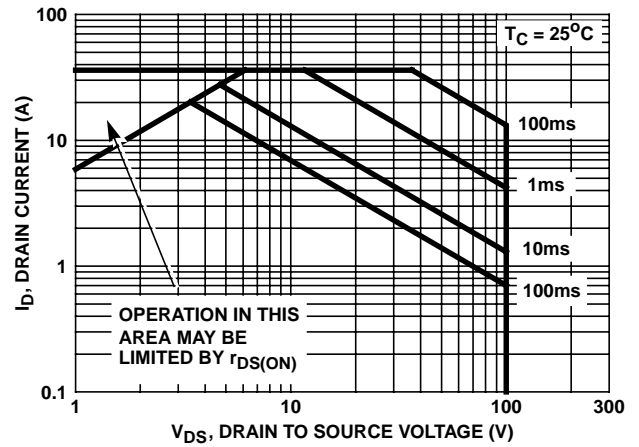


FIGURE 4. FORWARD BIAS SAFE OPERATING AREA

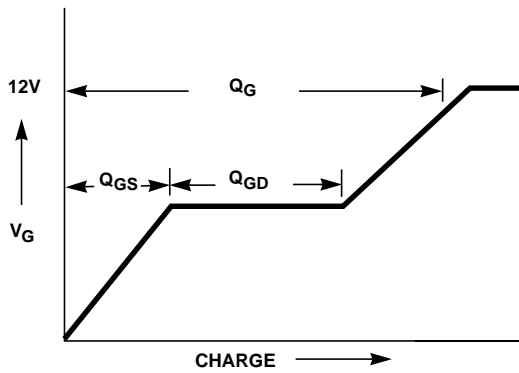


FIGURE 5. BASIC GATE CHARGE WAVEFORM

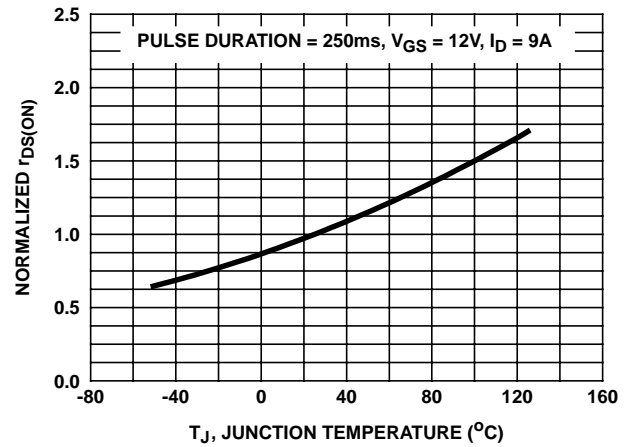


FIGURE 6. NORMALIZED  $r_{DS(ON)}$  vs JUNCTION TEMPERATURE

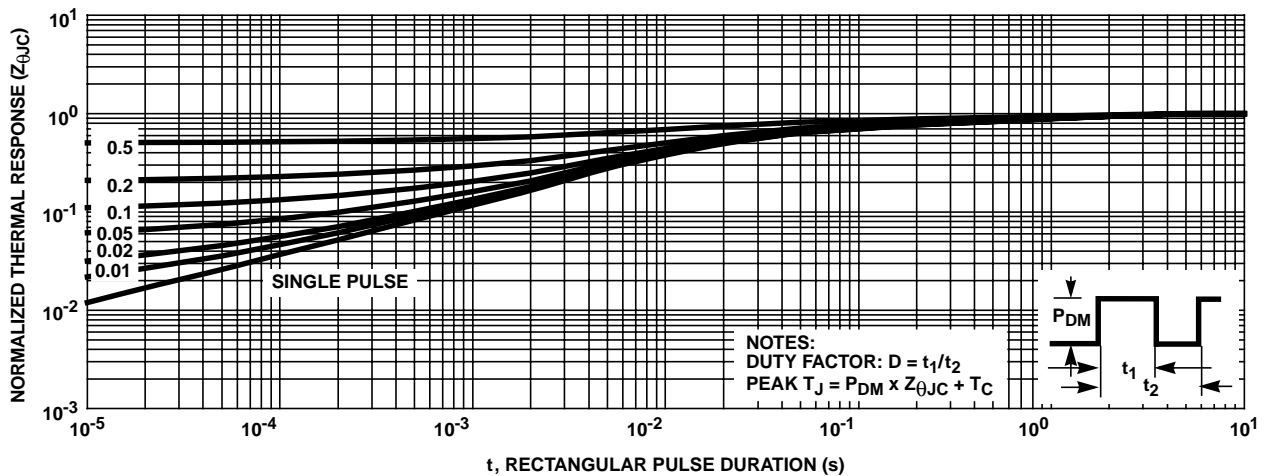


FIGURE 7. NORMALIZED MAXIMUM TRANSIENT THERMAL RESPONSE

Typical Performance Curves Unless Otherwise Specified (Continued)

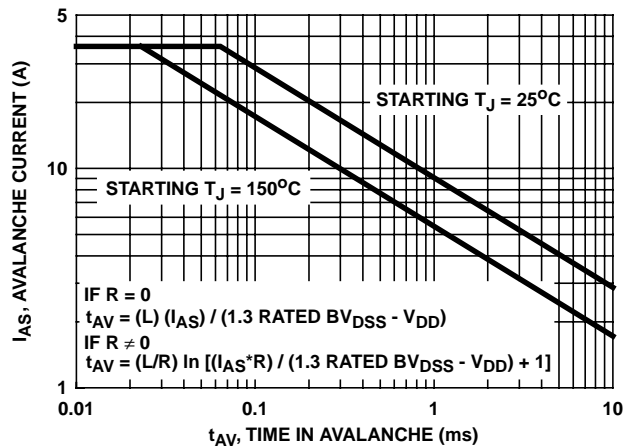


FIGURE 8. UNCLAMPED INDUCTIVE SWITCHING

Test Circuits and Waveforms

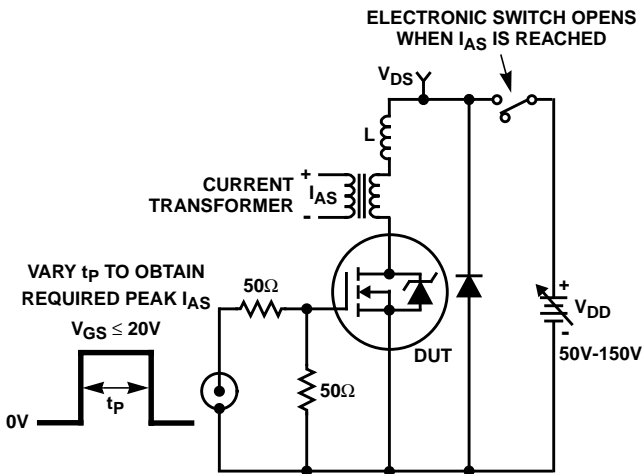


FIGURE 9. UNCLAMPED ENERGY TEST CIRCUIT

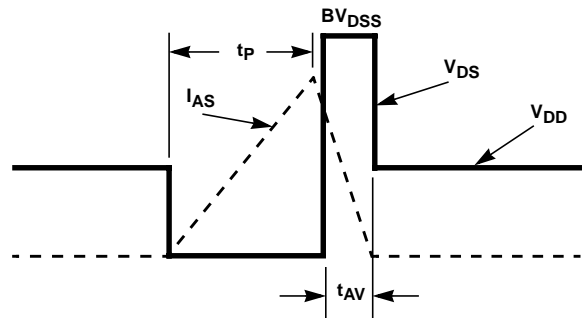


FIGURE 10. UNCLAMPED ENERGY WAVEFORMS

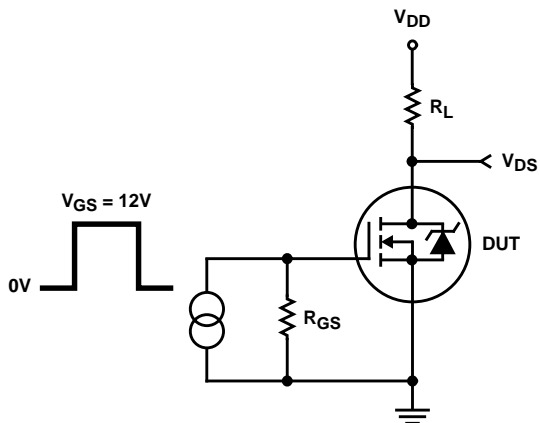


FIGURE 11. RESISTIVE SWITCHING TEST CIRCUIT

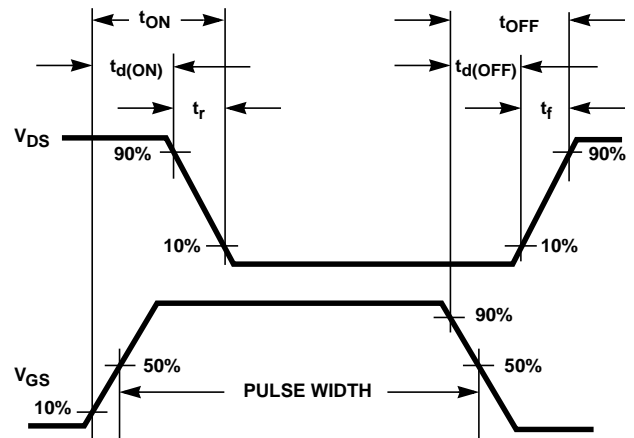


FIGURE 12. RESISTIVE SWITCHING WAVEFORMS

## Screening Information

Screening is performed in accordance with the latest revision in effect of MIL-S-19500, (Screening Information Table).

**Delta Tests and Limits (JANTXV Equivalent, JANS Equivalent)  $T_C = 25^\circ\text{C}$ , Unless Otherwise Specified**

PARAMETER	SYMBOL	TEST CONDITIONS	MAX	UNITS
Gate to Source Leakage Current	$I_{GSS}$	$V_{GS} = \pm 20\text{V}$	$\pm 20$ (Note 7)	nA
Zero Gate Voltage Drain Current	$I_{DSS}$	$V_{DS} = 80\%$ Rated Value	$\pm 25$ (Note 7)	$\mu\text{A}$
Drain to Source On Resistance	$r_{DS(ON)}$	$T_C = 25^\circ\text{C}$ at Rated $I_D$	$\pm 20\%$ (Note 8)	$\Omega$
Gate Threshold Voltage	$V_{GS(TH)}$	$I_D = 1.0\text{mA}$	$\pm 20\%$ (Note 8)	V

NOTES:

7. Or 100% of Initial Reading (whichever is greater).
8. Of Initial Reading.

## Screening Information

TEST	JANTXV EQUIVALENT	JANS EQUIVALENT
Gate Stress	$V_{GS} = 30\text{V}$ , $t = 250\mu\text{s}$	$V_{GS} = 30\text{V}$ , $t = 250\mu\text{s}$
Pind	Optional	Required
Pre Burn-In Tests (Note 9)	MIL-S-19500 Group A, Subgroup 2 (All Static Tests at $25^\circ\text{C}$ )	MIL-S-19500 Group A, Subgroup 2 (All Static Tests at $25^\circ\text{C}$ )
Steady State Gate Bias (Gate Stress)	MIL-STD-750, Method 1042, Condition B $V_{GS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$ , Time = 48 hours	MIL-STD-750, Method 1042, Condition B $V_{GS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$ , Time = 48 hours
Interim Electrical Tests (Note 9)	All Delta Parameters Listed in the Delta Tests and Limits Table	All Delta Parameters Listed in the Delta Tests and Limits Table
Steady State Reverse Bias (Drain Stress)	MIL-STD-750, Method 1042, Condition A $V_{DS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$ , Time = 160 hours	MIL-STD-750, Method 1042, Condition A $V_{DS} = 80\%$ of Rated Value, $T_A = 150^\circ\text{C}$ , Time = 240 hours
PDA	10%	5%
Final Electrical Tests (Note 9)	MIL-S-19500, Group A, Subgroup 2	MIL-S-19500, Group A, Subgroups 2 and 3

NOTE:

9. Test limits are identical pre and post burn-in.

## Additional Screening Tests

PARAMETER	SYMBOL	TEST CONDITIONS	MAX	UNITS
Safe Operating Area	SOA	$V_{DS} = 80\text{V}$ , $t = 10\text{ms}$	1.6	A
Unclamped Inductive Switching	$I_{AS}$	$V_{GS(PEAK)} = 15\text{V}$ , $L = 0.1\text{mH}$	36	A
Thermal Response	$\Delta V_{SD}$	$t_H = 100\text{ms}$ ; $V_H = 25\text{V}$ ; $I_H = 1\text{A}$	85	mV
Thermal Impedance	$\Delta V_{SD}$	$t_H = 500\text{ms}$ ; $V_H = 25\text{V}$ ; $I_H = 1\text{A}$	125	mV

**Rad Hard Data Packages - Intersil Power Transistors**

**TXV Equivalent**

**1. RAD HARD TXV EQUIVALENT - STANDARD DATA PACKAGE**

- A. Certificate of Compliance
- B. Assembly Flow Chart
- C. Preconditioning - Attributes Data Sheet
- D. Group A - Attributes Data Sheet
- E. Group B - Attributes Data Sheet
- F. Group C - Attributes Data Sheet
- G. Group D - Attributes Data Sheet

**2. RAD HARD TXV EQUIVALENT - OPTIONAL DATA PACKAGE**

- A. Certificate of Compliance
- B. Assembly Flow Chart
- C. Preconditioning - Attributes Data Sheet
  - Pre and Post Burn-In Read and Record Data
- D. Group A - Attributes Data Sheet
- E. Group B - Attributes Data Sheet
  - Pre and Post Read and Record Data for Intermittent Operating Life (Subgroup B3)
  - Bond Strength Data (Subgroup B3)
  - Pre and Post High Temperature Operating Life Read and Record Data (Subgroup B6)
- F. Group C - Attributes Data Sheet
  - Pre and Post Read and Record Data for Intermittent Operating Life (Subgroup C6)
  - Bond Strength Data (Subgroup C6)
- G. Group D - Attributes Data Sheet
  - Pre and Post RAD Read and Record Data

**Class S - Equivalents**

**1. RAD HARD "S" EQUIVALENT - STANDARD DATA PACKAGE**

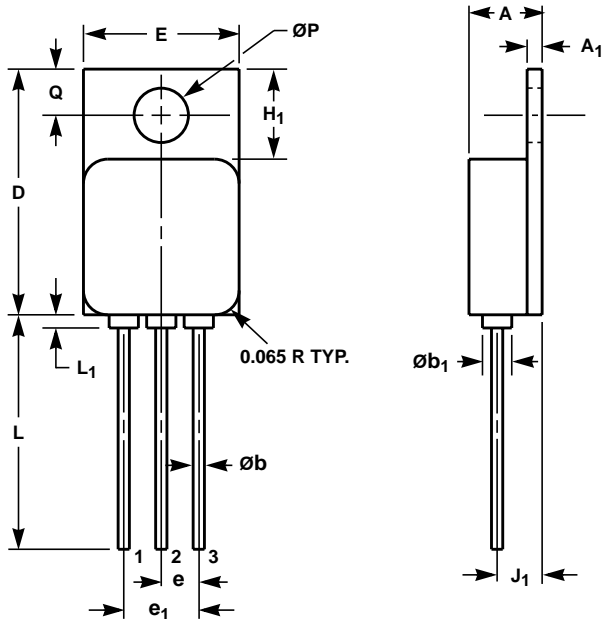
- A. Certificate of Compliance
- B. Serialization Records
- C. Assembly Flow Chart
- D. SEM Photos and Report
- E. Preconditioning - Attributes Data Sheet
  - HTRB - Hi Temp Gate Stress Post Reverse Bias Data and Delta Data
  - HTRB - Hi Temp Drain Stress Post Reverse Bias Delta Data
- F. Group A - Attributes Data Sheet
- G. Group B - Attributes Data Sheet
- H. Group C - Attributes Data Sheet
- I. Group D - Attributes Data Sheet

**2. RAD HARD MAX. "S" EQUIVALENT - OPTIONAL DATA PACKAGE**

- A. Certificate of Compliance
- B. Serialization Records
- C. Assembly Flow Chart
- D. SEM Photos and Report
- E. Preconditioning - Attributes Data Sheet
  - HTRB - Hi Temp Gate Stress Post Reverse Bias Data and Delta Data
  - HTRB - Hi Temp Drain Stress Post Reverse Bias Delta Data
  - X-Ray and X-Ray Report
- F. Group A - Attributes Data Sheet
  - Subgroups A2, A3, A4, A5 and A7 Data
- G. Group B - Attributes Data Sheet
  - Subgroups B1, B3, B4, B5 and B6 Data
- H. Group C - Attributes Data Sheet
  - Subgroups C1, C2, C3 and C6 Data
- I. Group D - Attributes Data Sheet
  - Pre and Post Radiation Data

**TO-257AA**

**3 LEAD JEDEC TO-257AA HERMETIC METAL PACKAGE**



SYMBOL	INCHES		MILLIMETERS		NOTES
	MIN	MAX	MIN	MAX	
A	0.190	0.200	4.83	5.08	-
A <sub>1</sub>	0.035	0.045	0.89	1.14	-
Øb	0.025	0.035	0.64	0.88	2, 3
Øb <sub>1</sub>	0.060	0.090	1.53	2.28	-
D	0.645	0.665	16.39	16.89	-
E	0.410	0.420	10.42	10.66	-
e	0.100 TYP		2.54 TYP		4
e <sub>1</sub>	0.200 BSC		5.08 BSC		4
H <sub>1</sub>	0.230	0.250	5.85	6.35	-
J <sub>1</sub>	0.110	0.130	2.80	3.30	4
L	0.600	0.650	15.24	16.51	-
L <sub>1</sub>	-	0.035	-	0.88	-
ØP	0.140	0.150	3.56	3.81	-
Q	0.113	0.133	2.88	3.37	-

**NOTES:**

1. These dimensions are within allowable dimensions of Rev. B of JEDEC TO-257AA dated 9-88.
2. Add typically 0.002 inches (0.05mm) for solder coating.
3. Lead dimension (without solder).
4. Position of lead to be measured 0.150 inches (3.81 mm) from bottom of dimension D.
5. Die to base BeO isolated, terminals to case ceramic isolated.
6. Controlling dimension: Inch.
7. Revision 1 dated 1-93.

**WARNING!**

**BERYLLIA WARNING PER MIL-S-19500**

Packages containing beryllium oxide (BeO) shall not be ground, machined, sandblasted, or subject to any mechanical operation which will produce dust containing any beryllium compound. Packages containing any beryllium compound shall not be subjected to any chemical process (etching, etc.) which will produce fumes containing beryllium or its' compounds.

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